

Session Chair in ITC2019

28/February 10:20-11:40 2F Hall

Keynote

Prof. Mamoru Furuta, Kochi University of Technology, Japan

28/February 13:30-15:45 2F Hall

Symposium 温故拓新

Prof. Byung Seong Bae, Hoseo University, Korea

Prof. Tayeb Mohammed-Brahim, Universite Rennes 1, France

1/March 9:30-10:35 2F Hall

Session 2H Oxide TFTs-I

Prof. Jin Jang, KyungHee University, Korea

1/March 9:30-10:40 4F Room A

Session 2A Organic TFTs

Prof. Olivier Bonnaud, University of Rennes 1, France

1/March 11:00-12:15 2F Hall

Session 3H Crystallization and Si-related devices

Prof. Radu A Sporea, University of Surrey, United Kingdom

1/March 11:00-12:05 4F Room A

Session 3A Printable & Flexible devices-I

Dr. Junghwan Kim, Tokyo Institute of Technology, Japan

1/March 14:00-15:12 2F Hall

Student Session 1

Dr. Juan Paolo Bermundo, Nara Institute of Science and Technology, Japan

Dr. Koswaththage Charith Jayanada, Sony Co., Japan

1/March 14:00-15:12 4F Room A

Student Session 2

Dr. S G Mehadi Aman, Kochi Univ. of Technology, Japan

Dr. Jean de Dieu Biregeya Mugiraneza, Sharp Co., Japan

1/March 15:30-16:50 2F Hall

Session 4H Printable & Flexible devices-II

Prof. Naoto Matsuo, University of Hyogo, Japan

Prof. Wenchang Yeh, Shimane University, Japan

1/March 15:30-16:50 4F Room A

Session 4A Novel application for TFTs

Prof. Munpyo Hong, Korea University, Korea

Prof. Chuan Liu, Sun Yat-sen University, China

2/March 9:00-9:55, 10:10-11:05 4F Room A

Session 5A Thin-Film technologies and device physics

Prof. Takashi Noguchi, University of the Ryukyus, Japan

Prof. Kazunori Ichikawa, Matsue College, Japan

2/March 9:00-9:50, 10:10-10:45 4F Room B

Session 5B Oxide TFTs-II

Dr. Guglielmo Fortunato, IMM-CNR, Italy

Prof. Qing Wan, Nanjing University, China